

Modified carbon-containing electrodes in stripping voltammetry of metals. Part II. Composite and microelectrodes

Natalya Yu. Stozhko · Natalya A. Malakhova ·
Mikhail V. Fyodorov · Khiena Z. Brainina

Received: 19 October 2007 / Revised: 21 October 2007 / Accepted: 21 October 2007 / Published online: 21 December 2007
© The Author(s) 2007

Abstract The second part of the review, which covers modified carbon-containing electrodes, describes composite and microelectrodes. Electrodes made of commercial and laboratory carbon-containing composite materials are discussed. Impregnated and thick-film electrodes and microelectrodes made of carbon fibers form a separate group. Various modifiers and methods of electrode modification are presented. Prospects for the future development of solid-state modified electrodes are considered.

Keywords Carbon-containing electrodes · Modified electrodes · Composite electrodes · Microelectrodes · Stripping voltammetry · Metal ions determination

Graphitized carbon and composite electrodes

The advancement of modern engineering and the use of new principles and approaches to the synthesis of carbon materials have facilitated the development of new commercial carbon-graphite materials with assigned properties. The use of the following commercially available electrode materials is reported in the literature: pencil lead [1–3]; spectral [4, 5], pyrolytic [6], and felt [7] graphites; carbon glass ceramic [8–10]; nonwoven graphite films [11]; carbon film resistors; and switches [12–16]. In most cases, electrodes of these materials are modified by metal films (mercury, copper, and bismuth), molecularly imprinted

TiO₂ [17]. The occurrence in the last decade of new types of carbon materials “from carbon nanotubes to edge plane pyrolytic graphite” [18, 19] has significantly changed the scope and sensitivity of electroanalytical methods for the measurement of diverse targets from metals ions to biological markers. Investigators considered in detail electrochemical characteristics [20] and practical use [21] of the “edge” plane pyrolytic graphite, which proved to have a wider interval of working potentials and a low detection limit as compared to those of the basal pyrolytic graphite and GC. For example, in situ bismuth film modified edge plane pyrolytic graphite electrode was successfully applied to the ultra trace simultaneous determination of cadmium(II) and lead(II) with detection limit $5.5 \cdot 10^{-10}$ and $4 \cdot 10^{-10}$ M, respectively [22].

Synthetic diamonds (nitrogen- [23, 24] and boron-doped [25–49]) have come into use quite recently for electrochemical measurements. In particular, a gold-coated, boron-doped, diamond thin-film electrode was used for total inorganic arsenic detection in real water samples [50]. Unlike properties of other carbon materials, which are widely used in electroanalysis, properties of synthetic diamonds became the subject of comprehensive study just about 10 years ago. The research was hindered by two circumstances: shortage of the material and the absence of conduction. The situation radically changed with the advent of highly efficient methods for growing of polycrystalline diamond compounds.

A more efficient separation, accumulation, and determination of components is achieved with electrodes of composite materials made of graphite, carbon, glassy carbon, or diamond powders and binders such as paraffin, epoxy resins, methacrylate, silicon, styrene–acrylonitrile copolymer, polyester, and silica gel. The reviews [51–54] deal with properties and applications of various composite

N. Y. Stozhko (✉) · N. A. Malakhova · M. V. Fyodorov ·
K. Z. Brainina
Ural State University of Economy,
8th March St. 62,
620219 Ekaterinburg, Russia
e-mail: sny@usue.ru

materials. Some original papers describe the use of unmodified electrodes made of graphite [55–62], glassy carbon [63], template carbon [64] –polymer composites, a composite based on natural and synthetic diamonds [65], nanocomposite made of carbon nanofibers [66], and a carbon-containing material prepared by a sol-gel technology [67, 68]. Much attention is given for the study of electrochemical properties and application of graphite-epoxy composite electrodes [69–72]. Specific features of the last material are its strength, chemical inertness, absence of impurities, nonswelling in water solutions, stability in organic solvents for prolonged periods, ease and simplicity of fabrication, and secure fixing of water-soluble reagents.

Table 1 gives examples of the use of modified composite electrodes in stripping voltammetry with the composite materials made under industrial and laboratory conditions using simple sol-gel, sono-gel, spin-casting, and molding technologies [73, 74–92]. The electrodes shown in the table can be divided into two groups: those made of carbon- (soot, amorphous carbon) [73–79] and those made of graphite-containing [80–92] materials. It should be noted that the detection limit of graphite-containing materials is somewhat higher than that of carbon-containing materials. Composite electrodes may be used to achieve the electrochemical response of ground solids, iron pigments, and insoluble samples [93, 94].

The bulk or surface modification of composite materials by metals or organic compounds considerably reduces the detection limit for metal cations. Silicon–carbon electrodes were proposed for determination of Cu (II), Pb (II), and Zn (II) after modification by mercury [76]; Ni (II) after modification by dimethyl glyoxime [77]; Os (IV) after modification by 9-phenyl-3-fluorone [78]; and Cu (I), Fe (II), and Ni (II) after modification by neocupferron, phenanthroline derivatives, and dimethylglyoxime, respectively [79]. A satisfactory reproducibility of responses of elements to be determined, a high selectivity, and the time stability of sol-gel electrodes can be noted.

Modified electrodes of composite materials are attractive because not only their surface but also the bulk can be easily modified at the stage of the composite formation [73–75, 77–80, 84–86, 90–92], facilitating fabrication of more reproducible electrodes. Simplicity of technologies used for production of many current-conducting composite materials with preset properties makes them promising for electroanalysis applications.

Impregnated graphite electrodes

Impregnated graphite electrodes (IGE), which have found application in the electroanalytical practice, are basically of two types: those impregnated with a paraffin–polyethylene

mixture and those with epoxy resins. IGE are widely used by electroanalysts in Russia. Unmodified [95, 96] and modified [97–129] IGE, shown in Table 2, are used in electrochemical inorganic analysis. IGE are modified by metals (Hg, Au, Cu, Tl, Jr) [97, 98–114], polymer films fixing the modifier and capable of the ion exchange [115], and Mo (IV) oxocomplexes [116, 117]. The IGE surface has good adsorbability and, hence, is readily modified by reagents specific for determined ions [118–129]. The IGE surface is modified most frequently, but examples of the IGE bulk modification can be found too [118, 119]. In this case, porous graphite is first held in an acetone solution of 2-mercaptopbenzoxazole and then impregnated with a two-component epoxy compound under exposure to ultrasound. IGE modified by this method were used to determine Ag (I) and Hg (II). They were additionally modified *in situ* by mercury and rhodamine for measurements of Bi (III) and Au (III), respectively.

IGE are widely used in abrasive stripping voltammetry developed by Scholtz et al. [130]. Abrasive stripping voltammetry is a new electroanalytical technique designed for qualitative and quantitative analysis of solid materials. The essence of this method is a recording of the voltammetric response of a set of solid microparticles of the analyte immobilized on an inert electrode (most frequently paraffin-impregnated graphite) both unmodified and modified, for example, with zeolites [131] immersed in an appropriate electrolyte. Voltammetry of microparticles is a rapidly growing field of research. This scheme was previously used to analyze metals, alloys, minerals, natural and synthetic sulfosalts, sulfides, and ceramic materials [132–138].

Thick-film carbon-containing electrodes

So-called “screen-printed” or “thick-film” electrodes have been used on a wide scale recently. They are reproducible and inexpensive. Thanks to their good electrochemical and metrological characteristics, these electrodes can serve for environmental monitoring and foodstuff quality control [139]. Thick-film electrodes are made of carbon- [140], graphite- [141, 142], carbon-nanotube-containing [143] inks or special current-conducting, e.g., graphite-epoxy, pastes. The design and the fabrication technology of the electrodes, as described, for example, in [144], allow easy modification of their surface by immobilizing a modifier on the electrode surface or adding it to the ink before the electrode is made.

Table 3 gives examples of the use of modified thick-film electrodes for voltammetric determination of elements [145, 146–192]. Metals and their oxides are the most common modifiers [145–163]. Sometimes the film electrodes are

Table 1 Modified composite electrodes

Electrode material/ modifier	Manner	Analyte	Detection limit, M	Supporting electrolyte	Sweep mode	Purge ^a	Sample	Ref.
CC/Ag/[Fe(CN) ₆] CC/Au	bulk bulk	Fe (III) Hg (II)	7·2·10 ⁻⁶ 1·10 ⁻¹⁰	0.1 M KNO ₃ 0.035 M H ₂ SO ₄ + 2 mM KCl	DP CSV LS ASV	+	BGD Waters	[73] [74, 75]
CCSG /Hg	in situ	Cu (II), Pb (II), Zn (II)	1·10 ⁻⁸ (Pb)	0.1 M HNO ₃ + 2·10 ⁻⁵ M Hg (II) (Pb), 0.1 M NaAc (Cu, Pb, Zn)	DP ASV	–	Fuel	[76]
CCSG/DMG	bulk	Ni (II)	2·6·10 ⁻⁶	0.1 M amm.buff. (pH 8.2)	DP CSV	–	Waters	[77]
CCSG/9P3F	bulk	Os (IV)	2·4·10 ⁻⁹	0.15 M NaF	DP ASV	–	Waters	[78]
CCSG/DMPT (1); DMG (2); neocuproine (3)	bulk	Fe (II) (1); Ni (II) (2); Cu (I) (3)	7·10 ⁻⁶ (Fe) 1·10 ⁻⁹	NaOH + 0.5 M TFAA (pH 2) (Fe), NaAc (pH 6) (Cu), TFAA (pH 9.2) (Ni)	SQW ASV	–	SS of leaves	[79]
GCSG/DAN	bulk	Se (IV)	4·5·10 ⁻¹⁴	0.1 M HCl	LS CSV	–	Waters	[80]
GCSG/RNSH	ex situ	Ag (I)	7·10 ⁻⁹	0.1 M McIlvane buffer (pH 5)	DP ASV	–	Human hair	[82]
GEC/PMTP	ex situ, on surface	Hg (II)	7·10 ⁻⁹	0.2 M B-R buff. (pH 4–8)	DP ASV	–	Waste waters	[81]
GEC /Hg,	ex situ	Cu (II), Pb (II), Cd(II)	4·4·10 ⁻¹⁰ (Cd)	0.05 M NaAc (pH 4.5)	SQW ASV	–	Waters	[83]
GEC /MBT	bulk	Bi(III), Hg (II), Cu (II)	4·2·10 ⁻⁹ (Hg); 3·6·10 ⁻⁹ (Bi); 9·5·10 ⁻⁸ (Cu)	B-R buff. (pH 3.8) (acc.); 1 M HCl (sweep)	DP ASV	+	SS, hair	[84]
GEC /8HQ	bulk	Sn (II)	4·6·10 ⁻¹⁰	0.1 M acetate buffer (pH 5.8) (acc.); 0.05 M HCl + 2 M CaCl ₂ (sweep)	DP ASV	–	SS, hair, juice, sea water	[85]
GCC /Ag	bulk	Pb (II)	1·10 ⁻⁸	0.1 M KCl + 0.005 M HCl	DP ASV	+	Waters	[86]
GCC /Hg	in situ	Pb (II)	9·7·10 ⁻⁹	0.1 M H ₂ SO ₄ + 2·10 ⁻⁵ M Hg(NO ₃) ₂	LS ASV	–	BGD	[87]
GCC /Hg	in situ	Cu (II)	1·6·10 ⁻⁹	0.25 M H ₂ SO ₄ + 2·10 ⁻⁴ M Hg(I)	LS ASV	–	Waters	[88]
GCC /Hg (1); GCC/ DPCO (2); GCC (3)	in situ	Cu (II) (1); Pb (II) (1); Cd (II) (1); Zn (II) (1); Cr (VI) (2); Ni (II) (3); Ag (0) (3)	7·8·10 ⁻⁹ (Cu); 1·4·10 ⁻⁹ (Pb); 4·4·10 ⁻⁹ (Cd); 7·6·10 ⁻⁸ (Zn); 9·6·10 ⁻⁹ (Cr); 8·5·10 ⁻⁸ (Ni); 4·6·10 ⁻⁹ (Cu)	0.1 M HCl + 5·10 ⁻⁵ M Hg (II) (Cu, Pb, Cd); NaAc (pH 4–5) +2·10 ⁻⁴ M Hg (II) + 10 ⁻⁴ M Ga (III) (Zn); 0.5 M HCl + 10 ⁻⁶ M DPCO (Cr); FB buff. (pH 5–7) (Ni); 0.05 M H ₂ SO ₄ (Ag)	LS ASV (1, 3) LS CSV (2)	–	Model solutions	[89]
GCC /HgO	bulk	Cu (II), Pb (II), Cd (II)	7·9·10 ⁻¹⁰ (Cu); 2·4·10 ⁻¹⁰ (Pb); 4·4·10 ⁻¹⁰ (Cd)	0.1 M KCl + 0.01 M HCl	LS ASV	–	Waters	[90]
GCC + MWNT/C	bulk	Ag (I)	5·10 ⁻¹¹	0.5 M NaClO ₄	DP CSV	–	Waters	[91, 92]

CC carbon composite, CCSG carbon-containing silica gel, DMG dimethylglyoxime, 9P3F 9-phenyl-3-fluorone, DMPT 4,7-dimethyl-1,10-phenanthroline, GCSG graphite-containing silica gel, DAN diaminonaphthalene, RNSH 5-(4-dimethyl amino benzyliden)-rhodamin, SGС sonogel-carbon, PMTP poly-3-methylthiophene, GEC graphite-containing composite, MBT 2-mercaptobenzothiazole, 8HO 8-hydroxyquinoline, DPCO diphenyl carbazole, MWNT multi-walled nanotubes, TCC thiacyrown compound, bulk modifier introduced to electrode bulk preliminary, ex situ modifier fixed on surface preliminary, in situ formation of modifying layer during deposition of substance to be determined, NaAc sodium acetate, *amm.buff.* ammonium buffer, TFAA trifluoroacetic acid, *B-R buff.* Britton-Robinson buffer, *ac.* stage of electrochemical accumulation, *FB buff.* fluoride-borate buffer, *EDTA* ethylenediaminetetraacetic acid, *DP differential-pulse.* CSV cathodic stripping voltammetry, LS linear sweep, ASV anodic stripping voltammetry, SQW square-wave, BGD supporting electrolyte, SS standard sample a “+”, after, “–” without oxygen removal

Table 2 Modified IGE

Electrode material/ modifier	Manner	Analyte	Detection limit, M	Supporting electrolyte	Sweep mode	Purge	Sample	Ref.
IGE-P /Hg	in situ	Pt (IV)	$1.3 \cdot 10^{-7}$	1 M HCl + 13. 4 mg L ⁻¹ Hg (II)	LS ASV	–	Biomaterials	[97]
IGE-P /Hg	in situ	Cu (II), Pb (II)	$3.7 \cdot 10^{-8}$ (Pb); $1.2 \cdot 10^{-7}$ (Cu)	0.1 M HCl + $1 \cdot 10^{-4}$ M Hg (II) + 1.2 M NaSCN	LS ASV	–	Model solutions	[98]
IGE-P / Hg + Cu	in situ	Se (IV)	$2.5 \cdot 10^{-7}$	0.1 M HCl + $2.5 \cdot 10^{-5}$ M Hg (II) + $3 \cdot 10^{-5}$ M Cu(II)	SQW CSV	+	Foodstuffs	[99]
IGE-R	ex situ	Au (III)	$5 \cdot 10^{-9}$	0.1 M HCl	LS ASV	–	Rocks	[100]
IGE-R /Hg	ex situ	Tl (III)	$9.8 \cdot 10^{-12}$	0.05 M EDTA (pH 4.4)	DP ASV	+	Waters	[101]
IGE-R /Hg	ex situ	Cu (II), Pb (II), Cd (II)	$6.3 \cdot 10^{-9}$ (Cu); $4.8 \cdot 10^{-10}$ (Pb); $8.9 \cdot 10^{-10}$ (Cd)	0.5 M NaCl (pH 3)	LS ASV	–	Natural waters	[102]
IGE-R /Hg	ex situ	Pb (II), Cd (II), Zn (II)	10^{-10}	0.02 M KNO ₃ + 1 mM HCl (pH 3)	LS ASV	–	Model solutions	[103]
IGE-P /Au	ex situ	As (III)	$2.7 \cdot 10^{-10}$	0.02–0.1 M EDTA + citrate Na (pH 4–5)	LS ASV	+	Drinking, mineral waters, strong drinks	[104]
IGE-P /Au	ex situ	As (III), Hg (II)	$1.3 \cdot 10^{-8}$ (As); $2.5 \cdot 10^{-9}$ (Hg)	0.1 M HCl	LS ASV	–	Natural waters	[105]
IGE-P /Au	ex situ	Se (IV)	$3.8 \cdot 10^{-8}$	0.3 M HClO ₄	LS ASV	–	Waters	[106]
IGE-P /Au	ex situ (1), in situ (2)	As (III) (1), Se (IV) (1), Hg (II) (2)	$1.0 \mu\text{g g}^{-1}$ (As); $0.6 \mu\text{g g}^{-1}$ (Se); $0.3 \mu\text{g g}^{-1}$ (Hg)	0.02–0.05 M EDTA (As); 0.1–0.3 M HClO ₄ (Se); HClO ₄ , HNO ₃ , HCl + Au (III) (Hg)	LS ASV	–	Toys	[107]
IGE-P /Au	in situ	Hg (II)	$5 \cdot 10^{-10}$	0.02–0.05 M HClO ₄ (or 0.1 M HNO ₃) + $4 \cdot 10^{-6}$ M Au(III) + 5 mM Cl [–]	LS ASV	–	Natural waters, foodstuffs	[108, 109]
IGE-R /Au	ex situ	As (III), Cu (II)	$9.3 \cdot 10^{-8}$ (As); $1.1 \cdot 10^{-7}$ (Cu)	0.01 M H ₃ PO ₄ + 1 mM EDTA	LS ASV	–	Model solutions	[110]
IGE-R /Au	ex situ	Hg (II)	$5 \cdot 10^{-10}$	0.1 M HClO ₄ + 0.03 M HCl	DP ASV	+	Sea sediment	[111]
IGE-R /Au	ex situ	Hg (II)	$8 \cdot 10^{-10}$	0.1 M HCl	LS ASV	–	Waters, foodstuffs	[112]
IGE-R /Au (1); IGE-R / Cu (2)	ex situ (1), in situ (2)	As (III)	$2.3 \cdot 10^{-7}$ (1); $6.3 \cdot 10^{-7}$ (2)	0.05 M EDTA (1); 0.1 M HCl + $5 \cdot 10^{-6}$ M Cu (II) (2)	LS ASV	–	BGD	[113]
IGE-R/Tl or In	in situ	Hg (II)	$1 \cdot 10^{-8}$	0.1 M HCl + Tl (I) or In (III) (10:1=Hg:Tl)	LS ASV	–	Model solutions	[114]
IGE-P/nafion	ex situ	Ag (I)	$2 \cdot 10^{-10}$	0.01 M HNO ₃ + 0.03 M NaCl	LS ASV	–	Chemicals	[115]
IGE-P/Mo (VI)-OC	in situ	As (V)	$2.7 \cdot 10^{-9}$	NaCl (pH 2.5) + $1.5 \cdot 10^{-3}$ M Mo (VI)	SQW CSV	+	Waters, foodstuffs	[116]
IGE-R or IGE-P/Mo (VI)-OC	in situ	As (V)	$3 \cdot 10^{-9}$ (IGE-P); $2 \cdot 10^{-10}$ (IGE-R)	1.0 M (Na, H)Cl (pH 2.5) + $1.5 \cdot 10^{-3}$ M Mo(VI) + 30 vol. % 1,4-ioxane	DP CSV	–	Natural, sea waters, foodstuffs	[117]
IGE-R/MBO/ Rhodamine 6G	ex situ/in situ	Au (III)	$1.9 \cdot 10^{-10}$	0.1 M HCl + $1 \cdot 10^{-6}$ M Rhodamine 6G (acc.); 0.1 M HCl (sweep)	DP CVA DP CSV	–	Sea water	[118]
IGE-R/MBO (1); IGE-R/ MBO /Hg (2)	ex situ (1), ex situ/in situ (2)	Ag (I) (1), Hg (II) (1), Bi (III) (2)	$1.8 \cdot 10^{-10}$ (Ag); $1.9 \cdot 10^{-9}$ (Hg); $9.5 \cdot 10^{-9}$ (Bi)	Ag: 0.1 M NaAc (pH 4.3) (acc.); 0.07 M HCl (sweep); Hg: 0.1 M FB (pH 5.5) (acc.); 0.075 M KBr + 0.1 M HNO ₃ (sweep); Bi: B-R buff. (pH 3.8) + $5 \cdot 10^{-6}$ M Hg (II) (acc.); 1.0 M HCl (sweep)	DP ASV	+	Sea water, urine	[119]
IGE-R/ DPCD	in situ	Cr (VI)	$1 \cdot 10^{-9}$	0.15 M H ₂ SO ₄ + $5 \cdot 10^{-6}$ M DPCD	LS CSV	–	Natural, sea waters, draw of soils	[120, 121]
IGE-R/ DPCO	in situ	Mn (II)	$5 \cdot 10^{-9}$	amm.buff. (pH 9.2) + $3 \cdot 10^{-5}$ M DPCO	LS CSV	–	SS of Ni-alloy, natural waters	[122]

Table 2 (continued)

Electrode material/ modifier	Manner	Analyte	Detection limit, M	Supporting electrolyte	Sweep mode	Purge	Sample	Ref.
IGE-P/ ANTPR	in situ	Mo (VI)	$5 \cdot 10^{-10}$	0.3–2.0 M HCl + 0.05 M ANTPR + 0.03 M SCN [−]	LS ASV	–	Natural waters	[123]
IGE-R / DMG	in situ	Ni (II)	$3 \cdot 10^{-9}$	0.2 M NaCl + $2.5 \cdot 10^{-4}$ M DMG + 0.03 M NaCl + pyridine (pH 8–10)	LS CSV	–	Natural, waste waters	[124]
IGE-R /CE	ex situ (1), in situ (2)	Pd (II)	$5 \cdot 10^{-9}$ (1); $1 \cdot 10^{-8}$ (2)	0.1 M HClO ₄ (1); 0.1 M HClO ₄ + $1 \cdot 10^{-2}$ gL ^{−1} CE (2)	LS ASV	–	BGD	[125, 126]
IGE-P/ ANTPR	in situ	W (VI)	$1 \cdot 10^{-9}$	1 M H ₂ SO ₄ + 0.078 M NH ₄ SCN + 0.04 M ANTPR	DP ASV	–	Waters	[127]
IGE-P / 9P3F	in situ	Sb (III), Sn (IV)	$1 \cdot 10^{-7}$	0.05 M H ₂ SO ₄ + (2.5–3.0) $\cdot 10^{-6}$ M 9P3F	LS ASV	–	Ni, Cr, SS of steels and irons	[128, 129]

For abbreviations aside from those defined here, see Table 1

IGE-P impregnated graphite electrode soaked with paraffin and polyethylene, *IGE-R* impregnated graphite electrode soaked with epoxy resin, *Mo (VI)-OC* Mo(VI) oxocomplex, *MBO* mercaptobenzoxazole, *DPCD* diphenyl carbazide, *ANTPR* antipyrine, *CE* crown ether, *EDTA* ethylenediaminetetraacetic acid, *FB* phosphate buffer, *CVA* cathodic voltammetry

modified by inorganic [164–167], metalorganic [168–174], and organic substances [175–180]; self-assembled layers [181–184]; macrocyclic compounds [185–187]; polymeric films [188, 189]; and ion-exchange resins [190, 191]. Modified thick-film electrodes provide the detection limit of elements at a level of 10^{-8} – 10^{-10} M.

Plasma, laser, temperature, and electrochemical treatments of the surface of thick-film electrodes can influence its activity, increase the rate of electron transitions, and change the electrochemical process reversibility. Preliminary anodic polarization of an electrode [192] not only extended the range of the working potentials but also improved its sensitivity. Voltammetric, microscopic, and spectroscopic studies suggested that the reason for the favorable effect of the anodic activation on the electrochemical properties of the electrode was enrichment of its surface in new functional groups, removal of unwanted inclusions from the surface, and the increase in the surface roughness.

Carbon microelectrodes

Pioneering research into the kinetics of electrochemical reactions on microelectrodes (ME) with diameters of units to several tens of micrometers revealed that the electrodes demonstrated new properties as their diameter decreased. Specifically, capacitive currents, which are the main factor that limits fast electrochemical processes on solid electrodes, decrease to practically insignificant values, the mass transfer rate of the substance to ME increases, the

electrochemical equilibrium is established much faster than on standard electrodes, and the ohmic potential drop iR is negligibly small for ME. The unique properties of ME make it possible to analyze and use solutions with a high ohmic resistance, including pure solvents, in voltammetry and extend the range of test compounds, primarily organic substances and extracts. Growing attention is given to ME because they can serve as the basis for development of simply designed and, hence, easily realizable miniature sensors and detectors for operation in flowing liquid systems and measurement of bioactive substances in vivo. The electrochemical properties, constructions, fabrication methods, and analytical capabilities of ME are described in reviews and original papers [193–199].

Nonmetal ME are made of carbon, graphitized and glassy-carbon fibers, filaments, or carbon pastes. Carbon fibers are synthesized by thermal decomposition of fibers based on cellulose or polyacrylonitrile. They have large chemical resistance and good current conduction. Along with favorable properties of the carbon fiber, one should take into account its capacity for hydrogen and oxygen chemisorption especially at a potential of +1.4 V, which can lead to irreversible changes of the surface and the decrease in the detection limit of elements. In this connection, it is recommended [200] to realize the electrochemical accumulation of elements on carbon-fiber ME at potentials when the oxygen and the hydrogen adsorption is at a minimum. Unlike metal ME available in a variety of shapes (hemispherical, conical, cylindrical, disk, as a ring, or as a disk with a ring), carbon ME are generally shaped as a disk. When ME are made of the

Table 3 Modified planar carbon containing electrodes

Electrode material	Modifier	Manner	Analyte	Detection limit, M	Supporting electrolyte	Sweep mode	Sample	Ref.
(C) ink	Ag	in situ	Pb (II)	$4.8 \cdot 10^{-9}$	0.1 M HNO ₃ + 50 mM NaCl + 500 µg L ⁻¹ Ag (I)	DP ASV	BGD	[145]
(C) ink	Ag _{nano} or Au _{nano}	ex situ	Sb (III)	$6.8 \cdot 10^{-10}$ (Ag _{nano}); $9.4 \cdot 10^{-10}$ (Au _{nano})	B-R buff. (pH 2)	DP ASV	Sea water, PP	[146, 147]
(C) ink	Au	ex situ	Hg (II), CH ₃ Hg ⁺	$2.5 \cdot 10^{-9}$	0.05 M HCl	SQW ASV	BGD	[148]
(C) ink	Bi	ex situ	Pb (II)	$1.4 \cdot 10^{-9}$	0.01 M NaAc (pH 4.5)	SQW ASV	Waters	[149]
(C) ink	Hg	in situ	Pb (II)	$2.9 \cdot 10^{-9}$	1.0 M NaBr + 1.2 M HCl + 50 µM Hg (II) + 100 µg L ⁻¹ In (III)	SQW ASV	Blood	[150]
(C) ink	Hg	ex situ	Pb (II)	$1.4 \cdot 10^{-11}$	0.02 M NaAc (pH 4.2)	DP ASV SQW ASV	Waters, urine	[151]
(C) ink	Hg	in situ	Cu (II), Cd (II), Pb (II), Zn (II)	$1.9 \cdot 10^{-6}$ (Cu); $6.3 \cdot 10^{-7}$ (Cd); $3.1 \cdot 10^{-7}$ (Pb); $8.4 \cdot 10^{-7}$ (Zn)	0.1 M MgCl ₂ + 10 mM KHPh + 120 µg L ⁻¹ Hg (II)	DP ASV	BGD	[152]
(C) ink	Hg	ex situ	Pb (II), Cd (II)	10^{-7}	0.01 M HCl	SQW ASV	BGD	[153]
(C) ink	Hg	ex situ	Cu (II), Pb (II), Cd (II)	$7.9 \cdot 10^{-10}$ (Cd); $1.4 \cdot 10^{-10}$ (Pb)	0.02 M NaAc (pH 4.8)	DP ASV	Urine	[154]
(C) ink	Hg	ex situ	Cu (II), Pb (II), Cd (II), Zn (II)	$1.6 \cdot 10^{-9}$ (Cu); $8.9 \cdot 10^{-10}$ (Cd); $4.8 \cdot 10^{-10}$ (Pb); $1.5 \cdot 10^{-9}$ (Zn)	0.1 M NaAc (pH 4.0)	SQW ASV	Waters, wine	[155]
(C) ink	Hg/Cu	ex situ	Pb (II)	$3.9 \cdot 10^{-9}$	0.02 M NaAc	SQW ASV	Waters	[156]
(G-E) paste	Hg	in situ	Cu (II), Pb (II), Cd (II)	$4.4 \cdot 10^{-9}$ (Cd); $1.4 \cdot 10^{-9}$ (Pb); $1.6 \cdot 10^{-8}$ (Cu);	0.1–0.5 M HCl + $1 \cdot 10^{-4}$ M Hg (II)	LS ASV, DP ASV	BGD, blood	[157, 158]
(C) paste	Hg	in situ	Cd (II), Cu (II), Pb (II)	$2.5 \cdot 10^{-8}$ (Cd)	0.1 M KNO ₃ + 0.03 M HNO ₃ + 1 mM Hg(NO ₃) ₂ + 0.1 M Fe(NO ₃) ₃	LS ASV	Waters	[159]
Carbonized PAN	Hg	in situ	Pb (II); Cd (II)	$3.1 \cdot 10^{-9}$ (Pb); $1.8 \cdot 10^{-9}$ (Cd)	0.1 M NaAc (pH 4.2) + 10 mg L ⁻¹ Hg (II)	SQW ASV	Blood	[160]
(G) ink	Hg	ex situ	Cu (II), Pb (II), Cd (II)	$1.9 \cdot 10^{-9}$ (Pb); $8.9 \cdot 10^{-9}$ (Cd); $7.9 \cdot 10^{-9}$ (Cu)	0.1 M HCl (30 mM NaAc) (pH 4.7)	SQW ASV	Waters, soil	[161, 162]
Soot + resin + PVC	HgO	bulk	Cu (II), Cd (II), Pb (II)	$1.6 \cdot 10^{-8}$ (Cu); $8.9 \cdot 10^{-9}$ (Cd); $4.8 \cdot 10^{-9}$ (Pb)	0.10 M KNO ₃ + 0.024 M HCl	LS ASV	Waters	[163]
(G) ink	Hg ₂ Cl ₂	ex situ	Cu (II), Pb (II), Cd (II), Zn (II)	$2 \cdot 10^{-9}$ (Cu); $2 \cdot 10^{-10}$ (Cd); $1 \cdot 10^{-10}$ (Pb); $8 \cdot 10^{-10}$ (Zn)	0.5 M HCl (Cu, Pb, Cd); acetic-chloride buffer (Zn)	LS ASV; SQW ASV	Waters, wines	[164, 165]
(G-E) paste	Hg ₂ Cl ₂ /pyrocatechin	ex situ/ in situ	Fe (III)	$3.6 \cdot 10^{-10}$	0.1 M NaAc + $5 \cdot 10^{-4}$ M pyrocatechin	LS CSV	Waters	[166]
(G) ink	BiPO ₄	ex situ	Pb (II), Cd (II), Zn (II)	$2 \cdot 10^{-9}$ (Pb); $4 \cdot 10^{-9}$ (Cd); $8 \cdot 10^{-9}$ (Zn)	0.1 M acetate buffer (pH 4.5)	SQW ASV	BGD	[167]
(G-E) paste	Hg (1); DPCD (2); ANTPR (3); DPCO (4); DAN (5); DMG(6)	in situ	Cu (II), Pb (II), Cd (II), Zn (II) (1); Cr (VI) (2); Mo (VI), W (VI) (3); Mn (II) (4); Se(IV) (5); Ni (II) (6)	10^{-9} (Cu, Pb, Cd, Zn, Cr); $1 \cdot 10^{-9}$ (Mo); $3 \cdot 10^{-9}$ (W); $6 \cdot 10^{-9}$ (Mn); $1 \cdot 10^{-8}$ (Se); $1 \cdot 10^{-9}$ (Ni)	0.14 M NaCl + 0.04 M HCl + $1 \cdot 10^{-4}$ M Hg (II) (Cu, Pb, Cd, Zn); 0.15 M H ₂ SO ₄ + 5– 10^{-6} M DPCD (Cr); 0.5–0.9 M HCl + 0.03–0.07 M NH ₄ SCN + 0.02–0.05 M ANTPR (Mo, W); amm.buff. + $3 \cdot 10^{-5}$ M DPCO (Mn); 0.1 M HCl + $6.3 \cdot 10^{-5}$ M DAN (Se); 0.1 M KCl + $2.5 \cdot 10^{-4}$ M DMG (Ni)	DP ASV	Waters	[168, 169]

Table 3 (continued)

Electrode material	Modifier	Manner	Analyte	Detection limit, M	Supporting electrolyte	Sweep mode	Sample	Ref.
(G-E) paste	Hg-DDC; Hg-PDTC or HgAc + nafion (1); Au PDTC, AuCl_3 + nafion or HAuCl_4 (2)	ex situ	Cu (II), Pb (II), Cd (II), Zn (II), Sn (IV) (1); Hg (II) (Sn); (2); As(III) (2)	10^{-9} (Cu, Pb, Cd, Zn); $8 \cdot 10^{-9}$ (Sn); $2.5 \cdot 10^{-11}$ (Hg); $1.4 \cdot 10^{-8}$ (As)	0.1 M HCl (Cu, Pb, Cd, Zn); 4.6 g L ⁻¹ NH ₄ Cl + 9.6 g L ⁻¹ (NH ₄) ₂ C ₂ O ₄ + 9.4 g L ⁻¹ HCl + 10 mg L ⁻¹ MB (Sn); 0.1 M H ₂ SO ₄ + 4 mM HCl (Hg); 2 M HCl (As)	LS ASV; DP ASV	Juices, waters	[170– 174]
(G-E) paste	NRS	in situ	Co (II)	$7.3 \cdot 10^{-12}$	0.01 M citrate buffer + 5 10^{-5} M NRS	LS CSV	Waters	[175]
(G) ink	SF	ex situ	Cu (II), Pb (II), Cd (II), Zn (II)	$8 \cdot 10^{-9}$ (Cu); $3 \cdot 10^{-9}$ (Pb); $2 \cdot 10^{-9}$ (Cd); $8 \cdot 10^{-8}$ (Zn)	0.1 M NaAc + 0.35 M NaCl + 10^{-3} M HCl	LS ASV	Waters	[176]
(G) ink	SF	bulk	Mn (II)	$1 \cdot 10^{-9}$	0.1 M NaCl + 0.1 M amm. buff. (pH 9.2)	LS CSV	Waters	[177]
(C) ink (SGG) paste	DMG	bulk	Ni (II)	$8.5 \cdot 10^{-8}$	0.1 M amm. buff. (pH 9.2)	DP CSV	Waters	[178]
(G) ink	DAN	ex situ	Se (IV)	$1.3 \cdot 10^{-9}$	0.1 M HCl	LS CSV	Waters	[179]
(C) ink	Alizarin	bulk	Al (III)	$7.0 \cdot 10^{-7}$	0.1 M amm. buff. (pH 9)	DP ASV	Soils	[180]
(G) ink	Sol-gel film + PT	ex situ	Fe (II), Fe(III)	$1 \cdot 10^{-6}$	0.1 M acetate buffer	LS ASV	Waters, wines	[181, 182]
(G) ink	Ac-Phos SAMMS	ex situ	Pb (II)	$4.4 \cdot 10^{-9}$	0.3–0.5 M HCl	SQW ASV	BGD	[183]
(G) ink	Sal-SAMMS	ex situ	Eu (III)	$6.6 \cdot 10^{-8}$	0.05 M acetate buffer (pH 4.6–6.5) (acc.); 0.1–0.2 M NH ₄ Cl (sweep)	SQW ASV	BGD	[184]
(G) ink	Calix[4 or 6] arene	ex situ	Pb (II), Cd (II)	$2.4 \cdot 10^{-8}$ (Pb); $2.5 \cdot 10^{-8}$ (Cd)	1 M amm. buff. (pH 10.5-Pb, pH 6.5-Cd) (acc.); 0.1 M HCl (sweep)	DP ASV	Waters	[185, 186]
(C) ink	CEBM	ex situ	Pb (II), Cd (II)	$0.8 \cdot 10^{-8}$ (Pb); $0.6 \cdot 10^{-8}$ (Cd)	0.01 M KNO ₃ (pH 2)	DP ASV	ES	[187]
(G) ink	PAN	ex situ	Pb (II)	$7.2 \cdot 10^{-8}$	0.37 M amm. buff. (pH 10.5) (acc.); 0.1 M HCl (sweep)	DP ASV	Waters	[188]
(C) ink	SPE/pcPVP	ex situ	Hg (II)	$1.6 \cdot 10^{-8}$	0.01 M KCl + 0.02 M H ₂ SO ₄	DP ASV	CP	[189]
(C) ink	Semi chelate Q10R	bulk	Hg (II)	$1.0 \cdot 10^{-11}$	0.5 M NaCl + 0.1 M NaAc (pH 4.5)	DP ASV	Waters	[190]
(G) ink	Dowex 50W-X8	bulk	Cu (II)	$7.9 \cdot 10^{-9}$	5 mM FB (pH 5.7)	DP AVA	Waters	[191]

For abbreviations aside from those defined here, see Tables 1 and 2

(G) or (C) *ink* graphite- or carbon-containing ink, (G-E) *paste* graphite-epoxy paste, PAN polyacrylonitrile, PVC polyvinylchloride, (SGG) *paste* sol-gel graphite paste, DAN diaminonaphthalene, NRS nitroso-R salt, Hg-DDC mercury diethyldithiocarbamate, Hg-PDTC mercury pyrrolidine dithiocarbamate, HgAc mercury(II) acetate, Au-PDTC aurum pyrrolidine dithiocarbamate, Ac-Phos SAMMS acetamide phosphonic acid self-assembled monolayer on mesoporous silica, SF hetaryl-substituted formazan, SPE/pcPVP 1,5-dibromopentane partially (7%) cross-linked poly(4-vinylpyridine), KHPH potassium hydrophthalate, MB methylene blue, PLH poly-L-histidine, CEBM crown-ether based membrane, AVA anodic voltammetry, PP pharmaceutical preparations, CP cosmetic productions, ES environmental samples

carbon fiber, the critical importance is attached to the technology used to cover the fiber with the insulating material because the insulation quality ultimately determines the mechanical strength and the operating stability of the electrode. A new technology by which ME are covered with a quartz film solves this problem to some extent. The film is deposited from the vapor phase

including silicon carbide, hydrogen, and oxygen [201]. The components mutually interact to form quartz gradually precipitating on carbon fibers. Coatings made by this technology have no cracks and hermetically insulate the fibers.

The problem of measuring extremely low currents at the level of nano- and picoamperes on ME is solved by the use

of up-to-date, highly sensitive electrochemical equipment or ME arrays (MEA) whose desired signal can be integrated and measured by standard electrochemical analyzers and polarographs. ME systems are made using methods of microelectronics, electron- and ion-beam technologies, X-ray and high-temperature lithography, and photolithography.

It should be noted that physical methods of producing ME systems are rather expensive and laborious.

The lower detection limit of determinable concentrations on electrodes made of a single unmodified carbon or graphite fiber is 10^{-7} – 10^{-9} M [202–212]. Still lower detection limits of 10^{-8} – 10^{-10} M were achieved with

Table 4 Modified carbon micro(nano)electrodes

Electrode material/ modifier	Manner	Analyte	Detection limit, M	Supporting electrolyte	Sweep mode	Purge	Sample	Ref.
GF (d= 8 μm)/Hg	in situ	Cd (II), Pb (II)	$5 \cdot 10^{-10}$	0.84 mM NaAc	SQW ASV	–	BGD	[213]
CF /Hg	in situ	Pb (II)	$4.8 \cdot 10^{-10}$	$1 \cdot 10^{-7}$ M Hg (II)	LS ASV	–	Natural waters	[214]
CF (d= 8 μm)/Hg	in situ	Zn (II)	$1 \cdot 10^{-7}$	0.15 M FB + Hg (NO_3) ₂	SQW ASV	–	Insulin	[215]
CF /Hg	in situ	Cu (II), Pb (II)	$2.9 \cdot 10^{-9}$ (Pb); $3.1 \cdot 10^{-8}$ (Cu)	0.1 M KNO ₃ + 0.1 M HNO ₃ (pH 1) + 0.01 mM Hg(NO_3) ₂	LS ASV	+	Natural and mineral waters	[216]
CF (d= 30 μm)/Hg	in situ	Pb (II), Cd (II), Zn (II)	$1 \cdot 10^{-10}$	0.01 M KCl + $1 \cdot 10^{-6}$ M Hg (II) + 0.033 M HNO ₃	LS ASV	+	Natural waters, rainfalls	[217]
CF (d= 6 μm)/Hg	ex situ	Cu (II), Pb (II)	$1 \cdot 10^{-7}$	0.1 M NaAc	LS ASV	+	Natural waters	[218]
GCF (d= 10 μm)/Hg,	ex situ	Zn (II)	$7.6 \cdot 10^{-7}$	10 mM KNO ₃ + 10 mM HNO ₃	SQW ASV	–	BGD	[219]
GCF (d= 8 μm)/Hg	ex situ	Cu (II); Pb (II); Cd (II)	10^{-8}	0.01 M HCl	DP ASV, SQW ASV	+	Natural waters	[220]
CF (d= 30 μm)/Au	in situ	Hg (II)	$8.1 \cdot 10^{-11}$	0.1 M HClO ₄ + 5 mM HCl + $5 \cdot 10^{-7}$ M Au (III)	DP ASV	–	Natural waters	[221]
CF/Bi	in situ	Tl (I), Cd (II), Zn (II), Pb (II)	10^{-8} – 10^{-9}	0.1 M NaAc (pH 4.5) + 400 $\mu\text{g L}^{-1}$ Bi (III)	SQW ASV	–	BGD	[222]
CF/Bi/ cupferron	ex situ/ in situ	U (VI)	$1.3 \cdot 10^{-9}$	0.1 M NaAc (pH 4.6) + $7.5 \cdot 10^{-5}$ M cupferron	SQW ASV	–	Sea waters	[223]
CF (d= 7 μm)/Bi (1), ex (2); CF/Bi/ DMG (2)	ex situ/ in situ (1); Ni (II) (2)	Pb (II) (1), Cd (II) (1), Co (II) (Co); Ni (II) (2) (Ni)	$1.2 \cdot 10^{-9}$ $1.5 \cdot 10^{-9}$	0.05 M NaAc (pH 4.5) (Cd, Pb); 0.01 M amm.buff. (Co, Ni); (pH 9.2) + $5 \cdot 10^{-5}$ M DMG (Co, Ni) (Cd, Pb)	SQW CSV SQW ASV	–	Model solutions	[224]
CMEA /Hg	in situ	Cd (II), Pb (II)	$1.4 \cdot 10^{-9}$ $2.7 \cdot 10^{-9}$ (Cd)	0.1 M NaAc + $5 \cdot 10^{-5}$ M Hg(NO_3) ₂	SQW ASV	+	Drinking water	[225]
CMEA (d= 7 μm)/Hg	in situ	Cd (II), Pb (II)	$1 \cdot 10^{-6}$	0.1 M KNO ₃ (pH 1.7, HNO ₃) + 0.38 mM Hg (II)	LS ASV	+	Model solutions	[226]
CMEA (d= 10 μm)/Hg	in situ	Pb (II)	$1.3 \cdot 10^{-7}$	1.2 M HCl + 0.046 mM Hg (II)	SQW ASV	–	Blood	[227]
CNTA/Bi	in situ	Pb (II), Cd (II)	$2 \cdot 10^{-10}$ $3.6 \cdot 10^{-10}$ (Cd)	0.1 M acetate buffer (pH 4.5) + $5 \cdot 10^{-4}$ $\mu\text{g L}^{-1}$ Bi(III)	SQW ASV	–	BGD	[228]

For abbreviations aside from those defined here, see Tables 1 to 3

GF graphite fiber, CF carbon fiber, GCF glassy-carbon fiber, CFA carbon fiber array, CMEA carbon microelectrode array, CNTA carbon nanotubes array

mercury-, gold-, and bismuth-modified ME, MEA and CNTA [213–227]; see Table 4.

Future trends

Having passed the point of centuries and marched into the twenty-first century, voltammetry is advancing in the direction concisely characterized by Wang [229] as “faster, cheaper, simpler and better.” This is largely because the main line of research changed from elaboration of the theory and equipment to development and application of new electrodes, sensors, and transducers in electroanalysis. Special emphasis is on the solution/electrode interface and the selective response formed on this interface. A new generation of electrodes with chemical or physical modification of the surface is under development. A great number of studies concerned with selection of modifiers, their immobilization on the solid surface, and the use of chemically modified electrodes (ChME) provide strong evidence for sincere interest paid by researchers to this problem. A wealth of experience has been accumulated in development of ChME, some features specific to fixing of modifiers on various matrices have been established, and conditions have been formulated for the electrochemical accumulation and determination of some substances on modified electrodes. However, the phenomenological stage of the ChME development is not complete because a diversity of modifiers and variants of their immobilization on electrodes will give researchers a wide scope of work for a long time to come.

It follows from the literature survey that a very promising and hopeful line of development of electrochemical sensors is the use of nanoparticles in electroanalysis [230–232] and the creation of micro- and nanoelectrode arrays, which can uniquely measure the electrochemical response in nonconductive media and unstirred electrolytes. However, the technologies used for the production of ME ensembles are extremely complicated and unavailable for ordinary research laboratories, suggesting the need to develop new methods of their fabrication. The creation of ordered nanostructures by traditional methods is an impracticable task, and in this case, it is appropriate to use the “bottom to top” rather than the “top to bottom” strategy. A proven fact is that nanoparticles of similar dimensions, which are synthesized “from top” by dispersion and “from bottom” by construction from atoms, are sharply different. The structure of the initial sample is preserved in dispersion particles, whereas particles formed by aggregation of atoms can have another arrangement of atoms influencing the electronic structure and chemical properties. Furthermore, processes of self-organization and evolution of modified layers on graphite-containing electrodes are quite possible

because of the high surface energy of the graphite-containing matrix.

It is reasonable to expect that the next stage of development of solid-state electrodes will include comprehensive studies of the electrode surface, elaboration of physical concepts for prediction of properties and characteristics of modified electrodes, and transition from micro- to ultramicro- and nanostructures on the electrode surface that would profoundly alter its properties. At this stage of development, study, and use of electrochemical sensors, we shall have to answer a number of questions: how the surface microgeometry influences the electrochemical activity of the modifier and the response parameters, how machining of the surface influences the electrochemical activity of the modifier and the electrode process, how the surface of the modified electrode can be made reproducible and the response stable, how to avoid formation of passivating films which impair electroanalytical performance of the electrodes, and other questions. This task will require performing a comprehensive systematic study of all links in the integral chain “electrode surface–modifier–response–SV analysis.”

Acknowledgements Financial support of Russian Foundation for Basic Research (project No. 07-03-96070-r_ural_a) and International Science and Technology Center (projects Nos. 342, 2132 and 2897) is gratefully acknowledged.

Open Access This article is distributed under the terms of the Creative Commons Attribution Noncommercial License which permits any noncommercial use, distribution, and reproduction in any medium, provided the original author(s) and source are credited.

References

1. Bond AM, Mahon PJ, Schiewe J et al (1997) *Anal Chim Acta* 345:67
2. Demetriadis D, Economou A, Voulgaropoulos A (2004) *Anal Chim Acta* 519:167
3. Sun J-J, Guo L, Zhang D-F et al (2007) *Electrochim Commun* 9:283
4. Vakhobova RU, Rakhmonberdyev AD, Rachinskaya GF et al (1993) *J Anal Chem* 48:1053
5. Hu Z, Seliskar CJ, Heineman WR (1998) *Anal Chim Acta* 369:93
6. Liu J, Wang X, Chen G et al (2001) *Analyst* 126:1404
7. Yin Q, Brandon NP, Kelsall GH (2000) *J Appl Electrochem* 30:1109
8. Kamenev AI, Lushov KA (2001) *J Anal Chem* 56:429
9. Viter IP, Kamenev AI, Sidakov AA et al (1994) *J Anal Chem* 49:1295
10. Kamenev AI, Kovalenko MA (2000) *J Anal Chem* 55:659
11. Nadezhina LS, Pronina OV, Yakovleva NYu (1995) *J Anal Chem* 50:1164
12. Filipe OMS, Brett CMA (2003) *Talanta* 61:643
13. Brett CMA, Angnes L, Liess HD (2001) *Electroanalysis* 13:765
14. Pauliukaite R, Brett CMA (2005) *Electroanalysis* 17:1354
15. Huang M, Huang MJ, Faguy PW et al (1997) *Electroanalysis* 9:1201

16. Gouveia-Caridade C, Pauliukaitė R, Brett CMA (2006) *Electroanalysis* 18:854
17. Liu Z, Huan S, Jiang J et al (2006) *Talanta* 68:1120
18. Banks CE, Compton RG (2006) *Analyst* 131:15
19. Wildgoose GG, Banks GE, Leventis HC et al (2006) *Microchim Acta* 152:187
20. Wantz F, Banks CE, Compton RG (2005) *Electroanalysis* 17:655
21. Banks CE, Compton RG (2005) *Anal Sci* 21:1263
22. Kachosangi RT, Banks CE, Ji X, Compton RG (2007) *Anal Sci* 23:283
23. Zeng A, Liu E, Tan SN et al (2002) *Electroanalysis* 14:1110
24. Zeng A, Liu E, Tan SN et al (2002) *Electroanalysis* 14:1294
25. Kruusma J, Tomcik P, Banks CE et al (2004) *Electroanalysis* 16:852
26. Kruusma J, Banks CE, Lust E et al (2004) *Electroanalysis* 16:596
27. Babyak C, Smart R (2004) *Electroanalysis* 16:175
28. Tsai YC, Coles BA, Holt K et al (2001) *Electroanalysis* 13:831
29. Prado C, Wilkins SJ, Gründler P et al (2003) *Electroanalysis* 15:1011
30. Goodwin A, Lawrence AL, Banks CE et al (2005) *Anal Chim Acta* 533:141
31. Banks CE, Hyde ME, Tomčík P et al (2004) *Talanta* 62:279
32. Sonthalia P, McGaw E, Show Y et al (2004) *Anal Chim Acta* 522:35
33. Kruusma J, Banks CE, Compton RG (2004) *Anal Bioanal Chem* 379:700
34. Manivannan A, Ramakrishnan L, Seehra MS et al (2005) *J Electroanal Chem* 577:287
35. Song Y, Swain GM (2007) *Anal Chem* 79:2412
36. Goeting CH, Jones F, Foord JS et al (1998) *J Electroanal Chem* 442:207
37. Maeda Y, Ramaraj R, Rao TN et al (1999) *Electrochim Acta* 44:3441
38. Saterlay AJ, Marken F, Foord JS et al (2000) *Talanta* 53:403
39. Chatterjee A, Wiltshire R, Holt KB et al (2002) *Diamond Relat Mater* 11:646
40. McGaw EA, Swain GM (2006) *Anal Chim Acta* 575:180
41. Manivannan A, Kawasaki R, Tryk DA (2004) *Electrochim Acta* 49:3313
42. Dragoe D, Spătaru N, Kawasaki R et al (2006) *Electrochim Acta* 51:2437
43. Ghanem MA, Hanson H, Compton RG et al (2007) *Talanta* 72:66
44. Einaga Y, Sato R, Olivia H et al (2004) *Electrochim Acta* 49:3989
45. Roustom SEI, Foti G, Comminellis C (2005) *Electrochim Commun* 7:398
46. Saez V, Gonzalez-Garcia J, Kulandainathan MA et al (2007) *Electrochim Commun* 9:1127
47. Colley AL, Williams CG, Johansson UD et al (2006) *Anal Chem* 78:2539
48. Banks CE, Kruusma J, Moore RR et al (2005) *Talanta* 65:423
49. Tall OE, Jaffrezic-Renault N, Sigaud M et al (2007) *Electroanalysis* 19:1152
50. Song Y, Swain GM (2007) *Anal Chim Acta* 593:7
51. Tallman DE, Peterson SL (1990) *Electroanalysis* 2:499
52. Gun G, Tsionsky M, Lev O (1994) *Anal Chim Acta* 294:261
53. Rabinovich L, Lev O (2001) *Electroanalysis* 13:265
54. Chung DDL (2004) *J Mater Sci* 39:2645
55. Jin Y, Xu F, Miwa T (2000) *Electroanalysis* 12:610
56. Kirushov VN (2000) *Zavodsk Lab* 66/6:16
57. Kirushov VN, Vais AA, Masly AI (2000) *Zavodsk Lab* 66/8:9
58. Kirushov VN, Vais AA, Skvortsova LI (2001) *Zavodsk Lab* 67/12:16
59. Matakova RN, Kenzhekhanova ZhT, Badavamova GL (1999) *J Anal Chem* 54:1188
60. Kirushov VN, Kletenik YuB (1997) *Zavodsk Lab* 63/12:13
61. Bek RYU, Skvortsova LI, Kirushov VN et al (2001) *Zavodsk Lab* 67/2:3
62. Kletenik YuB, Aleksandrova TP (1997) *J Anal Chem* 52:280
63. Wang J, Kirgoz UA, Mo JW et al (2001) *Electrochim Commun* 3:203
64. Zimer AM, Bertholdo R, Grassi MT et al (2003) *Electrochim Commun* 5:983
65. Stefan RI, Bairu SG (2003) *Anal Chem* 75:5394
66. Dijk N, Fletcher S, Madden CE (2001) *Analyst* 126:1878
67. Cordero-Rando MM, Hidalgo-Hidalgo de Cisneros JL, Blanco E et al (2002) *Anal Chem* 74:2423
68. Opallo M, Saczek-Maj M (2001) *Electrochim Commun* 3:306
69. O'Hare D, MacPherson JV, Willows A (2002) *Electrochim Commun* 4:245
70. Carregalo S, Merkoçi A, Alegret S (2004) *Microchim Acta* 147:245
71. Scvortsova LI, Aleksandrova TP, Tarasova VA et al (2005) *J Anal Chem* 60:1284
72. Ramirez-Garcia S, Alegret S, Cespedes F et al (2002) *Analyst* 127:1512
73. Kahlert H, Scholz F (1997) *Electroanalysis* 9:922
74. Khustenko LA, Larina LN, Nazarov BF (2003) *J Anal Chem* 58:297
75. Khustenko LA, Larina LN (2005) *Zavodsk Lab* 71/4:9
76. Kopanica M, Stara V (1991) *Electroanalysis* 3:925
77. Wang J, Pamidi PVA, Nascimento VB et al (1997) *Electroanalysis* 9:689
78. Khoo SB, Ye R (2002) *Electroanalysis* 14:420
79. Ji Z, Guadalupe AR (1999) *Electroanalysis* 11:167
80. Stozhko NYU, Morosanova EI, Kolyadina LI, Fomina SV (2006) *J Anal Chem* 61:170
81. Zejli H, Sharrock P, Hidalgo-Hidalgo de Cisneros JL et al (2005) *Talanta* 68:79
82. Majidi MR, Asadpour-Zeynali K, Hosseini S-A (2007) *Electroanalysis* 19:364
83. Wang J, Brennsteiner A, Angnes L (1992) *Anal Chem* 64:151
84. Khan MR, Khoo SB (2001) *Analyst* 126:2172
85. Khoo SB, Ye R (1999) *Analyst* 125:895
86. Navrátil T, Šebková S, Kopanika M (2004) *Anal Bioanal Chem* 379:294
87. Albertus F, Allerena A, Alpizar J et al (1997) *Anal Chim Acta* 355:23
88. Tarasova VA, Kletenik YuB (1998) *Zavodsk Lab* 64/2:9
89. Bek RYU, Aleksandrova TP, Skvortsova LI et al (2002) *Electroanalysis* 14:1017
90. Seo K, Kim S, Parc J (1998) *Anal Chem* 70:2936
91. Shpigun LK, Kopytova NE (1997) *Zavodsk Lab* 63/3:5
92. Shpigun LK, Kopytova NE, Kamilova PM et al (1997) *J Anal Chem* 52:974
93. Domenech-Carbo A, Domenech-Carbo MT, Gimeno-Adelantado JV et al (2001) *Analyst* 126:1764
94. Almeida CMVB, Giannetti BF (2002) *Electrochim Commun* 4:985
95. Labuda J, Vaníčková M, Beinrohr E (1989) *Microchimica Acta* 1:113
96. Kolpakova NA, Kaminskaya OV, Yagovkina EV (1998) *Zavodsk Lab* 64/4:9
97. Kolpakova NA, Smyshlaeva EA, Tuzikova SA et al (2003) *J Anal Chem* 58:303
98. Tsupko TG, Turian YaI, Temerdashev ZA et al (1993) *J Anal Chem* 48:1947

99. Filichkina OG, Zakharova EA, Slepchenko GB (2004) *J Anal Chem* 59:541
100. Viltchinskaia EA, Zeigman LL (1996) *Electroanalysis* 8:92
101. Lukaszewski Z, Zembrzuski W, Piela A (1996) *Anal Chim Acta* 318:159
102. Brainina KZ, Viltchinskaia EA, Khanina RM et al (1992) *Electroanalysis* 4:549
103. Tur'yan YI, Strochkova EM, Kuselman I (1996) *Fresenius J Anal Chem* 354:410
104. Zakharova EA, Pichugina VM, Pikula NP (1998) *Zavodsk Lab* 64/5:9
105. Svintsova LD, Kaplin AA, Vartanian SV (1991) *J Anal Chem* 46:896
106. Zakharova EA, Filichkina OG, Pikula NP (1998) *Zavodsk Lab* 65/2:3
107. Filichkina OG, Zeeman LP, Zakharova EA et al (1999) *Zavodsk Lab* 65/2:8
108. Zakharova EA, Pichugina VM, Tolmacheva TL (1996) *J Anal Chem* 51:1000
109. Batalova IR, Zakharova EA, Slepchenko GB et al (2004) *J Anal Chem* 59:528
110. Kamenev AI, Liakhov AB, Orlov SE (2005) *J Anal Chem* 60:179
111. Korolczuk M (1997) *Fresenius J Anal Chem* 357:389
112. Viltchinskaia EA, Zeigman LL, Morton SG (1995) *Electroanalysis* 7:264
113. Kamenev AI, Orlov SE, Liakhov AB (2001) *J Anal Chem* 56:962
114. Nadezhina LS, Grilikhes MS, Demin VA et al (1994) *J Anal Chem* 49:974
115. Labuda J, Vanichkova M, Pavlischuk VV et al (1992) *J Anal Chem* 47:1297
116. Tekutskaia EE, Kravtsov VI (1998) *Zavodsk Lab* 65/7:8
117. Tekutskaia EE, Kondrat'ev VV, Osipova MV (1999) *J Anal Chem* 54:1289
118. Ye R, Khoo SB (1999) *Analyst* 124:353
119. Ye R, Khoo SB (1997) *Electroanalysis* 9:481
120. Malakhova NA, Chernysheva AV, Brainina KhZ (1991) *Electroanalysis* 3:803
121. Desimoni E, Genevini P, Tambone F et al (2000) *Electroanalysis* 12:337
122. Brainina KhZ, Chernysheva AV, Nikitina NA (1990) *Zavodsk Lab* 56/7:17
123. Popkova GN, Fedorova ND, Brainina KhZ (1991) *J Anal Chem* 46:778
124. Stenina LE, Chernysheva AV, Brainina KhZ (1997) *Zavodsk Lab* 63/5:1
125. Tsymbal MV, Turjan IY, Temerdashev ZA et al (1994) *Electroanalysis* 6:113
126. Brainina KHZ, Tsymbal MV, Temerdashev ZA (1992) *Zavodsk Lab* 58/3:11
127. Malakhova NA, Popkova GN, Wittman G et al (1996) *Electroanalysis* 8:375
128. Tobolkina NV, Fedorova ND (1993) *Zavodsk Lab* 59/12:16
129. Tobolkina NV, Fedorova ND, Brainina KhZ (1992) *Zavodsk Lab* 58/5:5
130. Grygar T, Marken F, Schröder U, Scholz F (2002) *Collect Czech Chem Commun* 67:163
131. Walcarius A (2006) *J Solid State Electrochem* 10:469
132. Scholz F, Nitschke L, Henrion G (1990) *Electroanalysis* 2:85
133. Scholz F, Lange B (1992) *Trends Anal Chem* 11:359
134. Zhang S, Meyer B, Moh G, Scholz F (1995) *Electroanalysis* 7:319
135. Doménech-Carbó A, Moya-Moreno M, Doménech-Carbo MT (2004) *Anal Bioanal Chem* 380:146
136. Doménech-Carbó A, Sánchez-Ramos S, Yusá-Marco DJ et al (2004) *Anal Chim Acta* 501:103
137. Fiedler DA, Albering JH, Besenhard JO (1998) *J Solid State Electrochem* 2:413
138. Ciglenečki I, Bura-Nakic E, Inzelt G (2007) *Electroanalysis* 19:1437
139. Brainina KhZ, Malakhova NA, Stojko NYu (2000) *Fresenius J Anal Chem* 368:307
140. Reeder GS, Heineman WR (1998) *Sensors and Actuators* 52:58
141. Honeychurch KC, Hawkins DM, Hart JP et al (2002) *Talanta* 57:565
142. Honeychurch KC, Hart JP, Cowell DC (2000) *Electroanalysis* 12:171
143. Wang J, Musameh M (1994) *Analyst* 129:25
144. Mooring L, Karousos NG, Livingstone C et al (2005) *Sensors and Actuators B: Chemical* 107:491
145. Bagel O, Lagger G, Girault HH et al (2001) *Electroanalysis* 13:100
146. Renedo O, Martinez JA (2007) *Electrochim Commun* 9:820
147. Renedo O, Martinez JA (2007) *Anal Chim Acta* 589:255
148. Wang J, Tian B (1993) *Anal Chim Acta* 274:1
149. Wang J, Lu J, Hocevar S et al (2001) *Electroanalysis* 13:13
150. Liu TZ, Lai D, Osterloh JD (1997) *Anal Chem* 69:3539
151. Wang J, Tian B (1992) *Anal Chem* 64:1706
152. Desmond D, Lane B, Alderman J et al (1998) *Sens Actuators B Chem* 48:409
153. Jasinski M, Grundler P, Flechsig GU et al (2001) *Electroanalysis* 13:34
154. Hart JP, Wring SA (1996) *Electroanalysis* 8:617
155. Wang J, Lu J, Tian B et al (1993) *J Electroanal Chem* 361:77
156. Zen JM, Chung HH, Kumar AS (2000) *Anal Chim Acta* 421:189
157. Brainina Kh, Schafer H, Ivanova A et al (1996) *Anal Chim Acta* 330:175
158. Brainina KhZ, Bond AM (1995) *Anal Chem* 67:2586
159. Weston MC, Anderson EC, Arumugan PU et al (2006) *Analyst* 131:1322
160. Wang J, Rongrong X, Baomin T et al (1994) *Anal Chim Acta* 293:43
161. Palchetti I, Cagnini A, Mascini M, Turner APF (1999) *Microchim Acta* 131:65
162. Palchetti I, Laschi S, Mascini M (2005) *Anal Chim Acta* 530:61
163. Choi JY, Seo K, Cho SR et al (2001) *Anal Chim Acta* 443:241
164. Malakhova NA, Miroshnikova EG, Stojko NYu, Brainina KhZ (2004) *Anal Chim Acta* 516:49
165. Stozhko NYu, Kozitsina AN, Chiavarini S et al (2007) *Ital J Food Sci* 19:254
166. Stojko NYu, Inzhevatova OV, Koljadina LI (2005) *J Anal Chem* 60:747
167. Malakhova NA, Stojko NYu, Brainina KhZ (2007) *Electrochim Commun* 9:221
168. Brainina Kh, Malakhova N, Ivanova A (1998) Solid carbon containing stripping voltammetry sensors. In: Nikolelis DP (ed) *Biosensors for direct monitoring of environmental pollutants in field*. Kluwer Academic, Norwell, pp 255–269
169. Brainina Kh, Henze G, Stojko N et al (1999) *Fresenius J Anal Chem* 364:285
170. Brainina KhZ, Ivanova AV, Malakhova NA (1997) *Anal Chim Acta* 349:85
171. Faller C, Henze G, Stojko N et al (1997) *Fresenius J Anal Chem* 358:670
172. Stojko N, Brainina Kh, Faller C, Henze G (1998) *Anal Chim Acta* 371:145
173. Faller C, Stojko N, Henze G, Brainina Kh (1999) *Anal Chim Acta* 396:195
174. Brainina KhZ, Stojko NYu, Shalygina ZhV (2002) *J Anal Chem* 57:1116

175. Stojko NYu, Inzhevatova OV (2004) *J Anal Chem* 59:949
176. Stojko NYu, Lipunova GN, Maslakova TI et al (2004) *J Anal Chem* 59:202
177. Stojko NYu, Inzhevatova OV, Koljadina LI, Lipunova GN (2005) *J Anal Chem* 60:187
178. Wang J, Nascimento VB, Lu J et al (1996) *Electroanalysis* 8:635
179. Stojko NYu, Morosanova EI, Koljadina LI et al (2006) *J Anal Chem* 61:170
180. Akhtar P, Devereaux HA, Downard AJ et al (1999) *Anal Chim Acta* 381:49
181. Stojko NYu, Morosanova EI, Koljadina LI, Azarova ZhM (2004) *J Anal Chem* 59:960
182. Stojko NYu, Morosanova EI, Koljadina LI, Fomina SV (2005) *Zavodsk Lab* 71/3:14
183. Yantasee W, Deibler LA, Flyxell GE et al (2005) *Electrochim Commun* 7:1170
184. Yantasee W, Flyxell GE, Lin Y (2006) *Analyst* 131:1342
185. Honeychurch KC, Hart JP, Cowell DC et al (2001) *Sensors and Actuators B Chemical* 77:642
186. Honeychurch KC, Hart JP, Cowell DC et al (2002) *Electroanalysis* 14:177
187. Parat C, Betelu S, Authier L et al (2006) *Anal Chim Acta* 573–574:14
188. Honeychurch KC, Hart JP, Cowell DC (2001) *Anal Chim Acta* 431:89
189. Shin Y, Kumar AS, Zen JM et al (2005) *Bull Jpn Chem Soc* 78:2130
190. Ugo P, Moretto LM, Bertoncello P et al (1998) *Electroanalysis* 10:1017
191. Neuhold CG, Wang J, Nascimento VB et al (1995) *Talanta* 42:1791
192. Wang J, Pedrero M, Sakslund H et al (1996) *Analyst* 121:345
193. Maystrenko VN, Rusakov IA, Budnikov GK (1992) *J Anal Chem* 47:1003
194. Štulík K (1999) *Electroanalysis* 11:1001
195. Feeney R, Kounaves SP (2000) *Electroanalysis* 12:677
196. Zoski CG (2002) *Electroanalysis* 14:1041
197. Budnikov GK, Kazakov VE, Poliakov YuN et al (1994) *J Anal Chem* 49:410
198. Matysik FM, Gläser P, Werner G (1994) *Fresenius J Anal Chem* 349:646
199. Baranski AS (2002) *Anal Chem* 74:1294
200. Doronin AN, Muntianu GG (1984) *J Anal Chem* 39:607
201. Zhao G, Giolando DM, Kirchhoff JR (1995) *Anal Chem* 67:2592
202. Mylonakis A, Economou A, Fielden PR et al (2004) *Electroanalysis* 16:524
203. Kamenev AI, Sidorov NV (1997) *J Anal Chem* 52:746
204. Muntianu GG (1998) *J Anal Chem* 53:1070
205. Muntianu GG (1998) *J Anal Chem* 53:312
206. Silva SM (1998) *Electroanalysis* 10:722
207. Silva SM, Bond AM (2003) *Anal Chim Acta* 500:307
208. Baldo MA, Daniele S, Mazzocchin GA (1998) *Electroanalysis* 10:410
209. Muntianu GG (2000) *J Anal Chem* 55:979
210. Sanna G, Pilo MI, Piu PC et al (2002) *Electroanalysis* 14:1512
211. Spano N, Panzanelli AA, Piu PC et al (2005) *Anal Chim Acta* 553:201
212. Bartlett PN, Denuault G, Sousa MFB (2000) *Analyst* 125:1135
213. Wojciechowski M, Balcerzak J (1991) *Anal Chim Acta* 249:433
214. Bumber AA, Nechitaylov YuN, Profatilova IA et al (2000) *J Anal Chem* 55:742
215. Barbosa RM, Rosario LM, Brett CMA et al (1996) *Analyst* 121:1789
216. Daniele S, Bragato C, Baldo MA (1997) *Anal Chim Acta* 346:145
217. Muntianu GG (2004) *J Anal Chem* 59:851
218. Baldo MA, Daniele S, Mazzocchin GA (1998) *Electroanalysis* 10:410
219. Petrovic SC, Dewald HD (1997) *Anal Chim Acta* 357:33
220. Emons H, Baade A, Schoning MJ (2000) *Electroanalysis* 12:1171
221. Muntianu GG (2001) *J Anal Chem* 56:614
222. Wang J, Lu J, Hocevar SB, Farias PAM (2000) *Anal Chem* 72:3218
223. Lin L, Thongngamdee S, Wang J et al (2005) *Anal Chim Acta* 535:9
224. Hutton EA, Hocevar SB, Ogorevc B (2005) *Anal Chim Acta* 537:285
225. Wang J, Armalis S (1995) *Electroanalysis* 7:958
226. Schiewe J, Oldham KB, Myland JC et al (1997) *Anal Chem* 69:2673
227. Feldman BJ, Osterloh JD, Hata BH et al (1994) *Anal Chem* 66:1983
228. Liu G, Lin Y, Tu Yi et al (2005) *Analyst* 130:1098
229. Wang J, Tian B, Wang J et al (1999) *Anal Chim Acta* 385:429
230. Hernandez-Santos D, Gonzalez-Garcia MB, Garcia AC (2002) *Electroanalysis* 14:1225
231. Katz E, Willner I, Wang J (2004) *Electroanalysis* 16:19
232. Welch CM, Compton RG (2006) *Anal Bional Chem* 384:601